

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re New National Phase Patent Application of)
Shinji MAEKAWA et al.)
International Application No. PCT/JP2004/016181)Attn: US/DO/EO
International Filing Date: October 25, 2004)
For: METHOD FOR FORMING WIRING, METHOD)
FOR MANUFACTURING THIN FILM TRANSISTOR)
OR AND DROPLET DISCHARGING METHOD)Date: April 12, 2006

PRELIMINARY AMENDMENT

United States Patent and Trademark Office
Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314

Sir:

Please preliminarily amend the subject application as follows: